

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE



Applicant(s): Hua Ji
Assignee: Mosel Vitelic, Inc.
Title: HDP CVD Process For Void-Free Gap Fill Of A High Aspect Ratio
Trench
Serial No.: 10/080,468 Filing Date: February 22, 2002
Examiner: Anh D. Mai Group Art Unit: 2814
Docket No.: M-12589US

Irvine, California
August 20, 2002

BOX AMENDMENT
COMMISSIONER FOR PATENTS
Washington, D. C. 20231

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RESPONSE TO OFFICE ACTION

Dear Sir:

In response to the Office Action dated May 20, 2002, Applicant submits the following amendments and remarks.

IN THE DRAWINGS

FIGS. 1-5 have been designated with a legend indicating "Prior Art" as requested and submitted on a separate paper showing the proposed changes in red. Accordingly, Applicant respectfully requests that the objection to the drawings be withdrawn.

IN THE SPECIFICATION

In accordance with 37 C.F.R. 1.121(c)(2)(ii), Attachment A provides marked up versions of the replacement paragraphs illustrating the newly introduced changes in the specification.

Please replace the paragraph on page 8, line 3 through line 22, with the following replacement paragraph:
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